



INFORMATION DISCLOSURE CITATION IN AN APPLICATION (PTO/SB/O8A)				ATTY. DOCKET NO. 1268-254		U.S. PATENT APPLICATION NO. 10/566,369	
				APPLICANT Oleg NAIGERTSIK et al.			
				FILING DATE January 30, 2006		GROUP	
U.S. PATENT DOCUMENTS							
EXAMINER'S INITIALS	PATENT NO.	DATE	NAME	CLASS	SUBCLASS	FILING DATE	
FOREIGN PATENT DOCUMENTS							
EXAMINER'S INITIALS	PATENT NO.	DATE	COUNTRY	Abstract	Translation	Equivalent	
/T.T./	0281034	9/1988	EP				
/T.T./	0581651	2/1994	EP				
/T.T./	0934773	8/1999	EP				
/T.T./	2703927	10/1994	FR				
/T.T./	2774906	8/1999	FR				
/T.T./	2780901	1/2000	FR				
/T.T./	19811900	9/1999	DE				
/T.T./	1319991	6/1973	GB				
OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)							
/T.T./	Aizawa et al., "Preparation of Spherical Hydrous Silica Oxide Particles under Acidic Condition via Sol-Gel Processing," JOURNAL OF SOL-GEL SCIENCE AND TECHNOLOGY 19, 329-332, 2000						
/T.T./	Avnir et al., "Organic Fluorescent Dyes Trapped in Silica and Silica-Titania Thin Films by the Sol-Gel Method Photophysical, Film and Cage Properties," JOURNAL OF NON-CRYSTALLINE SOLIDS 74, (1985), 395-406						
/T.T./	Barbe et al., "Sol-Gel Microspheres and Nanospheres for Controlled Release Applications," Controlled Release Society 29 th Annual Meeting Proceedings, #293, 545-546						
/T.T./	Butler et al., "An emulsion method for producing fine, low density, high surface area silica powder from alkoxides," JOURNAL OF MATERIALS SCIENCE 31, (1996), 1675-1680						
/T.T./	Federal Register, Vol. 67, No. 94, 34616-34620						
/T.T./	Hou et al., "Improvement of photofatigue resistance of spirooxazine entrapped in organic-inorganic composite synthesized via the sol-gel process," SPIE, Vol. 2288 Sol-Gel Optics III, (1994), 328-339						
/T.T./	Nakatsuka, "Surface Modification of Inorganic Pigments with Organic UV Absorbers," COLLOIDS AND SURFACES 34, (1988/89), 323-324						
/T.T./	Tatapudy et al., "Benzoyl Peroxide Microcapsules I. Preparation of Core Material," INDIAN DRUGS 32(6), (1995), 239-248						
EXAMINER /Thao Tran/ (04/02/2010)				DATE CONSIDERED 04/02/2010			

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to Applicant.

ALL REFERENCES CONSIDERED EXCEPT WHERE LINED THROUGH. /T.T./

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/T.T./	0025761	5/2000	WO	X			
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/T.T./	9235217	9/1997	JP	X			
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